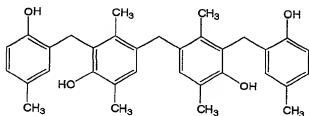
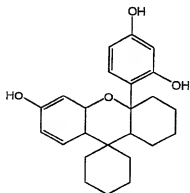


ABSTRACT OF THE DISCLOSURE

A composition includes (A) an alkali-soluble resin, (B) a quinonediazide ester of a compound represented by the following formula:



and (C) a compound represented by the following formula:



This composition is a positive photoresist composition that is excellent in sensitivity and definition and causes less shrink.